

Class	Subclass
438	787

U.S. UTILITY Patent Application

APPLICATION NO. 09/632425	CONT/PRIOR	CLASS 438	SUBCLASS 787	ART UNIT 2889	EXAMINER HEICDAY
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APPLICANTS
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TITLE
Process for depositing a porous, low dielectric constant silicon
oxide film

PTO-2040
12/99

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PTO-338A
(Rev. 6/99)

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